

JUN 21 2004

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

OFFICIAL

In re the application of: Smith *et al.*

Docket: TI-22782B

Appl. No.: 09/757,073

Examiner: E. Cameron

Filed: 1/8/01

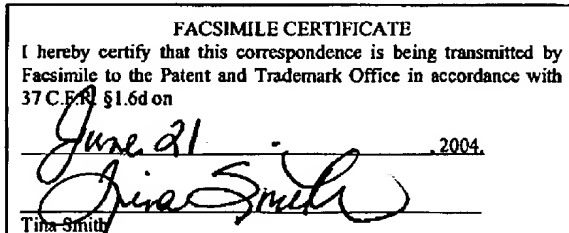
Art Unit: 1762

For: Polyol-Based Method For Forming Thin Film Aerogels On Semiconductor Substrates

REPLY PURSUANT TO 37 C.F.R. § 1.111

June 18, 2004

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450



Examiner:

In response to the Office Action dated April 19, 2004, please amend the above-identified patent application as follows:

IN THE SPECIFICATION

In the paragaragraph added on page 1, before line 1, replace the paragraph with

This application is a continuation of U.S. application number 09/115,854 filed 07/15/98—  
now patent 6,171,645—, which is a continuation of U.S. application number 08/748,926 filed  
11/14/96—now patent 5,807,607—, which claims priority from provisional application numbers:  
60/006,852 filed 11/16/1995, 60/006,853 filed 11/16/1995, 60/012,764 filed 3/4/1996, 60/012.800  
filed 3/4/1996, and 60/014,005 filed 3/4/1996.